

CLAIMS

1. A liquid crystal display device comprising:

a substrate;

thin film transistors formed on said substrate;

an insulation film defining first and second regions to cover said thin film transistors,

said first and second regions of said insulation film being different in thickness from each other; and

10 a light shielding film provided at portions underneath boundaries of said first and second regions.

2. The liquid crystal display device according to Claim 1, further comprising:

15 transparent electrode film formed on said first region;

and

reflective electrode film formed on said second region.

3. The liquid crystal display device according to Claim 1 or 2, wherein said light shielding film is made of the same material 20 as said thin film transistors.

4. A method of manufacturing a liquid crystal display device comprising the steps of:

25 forming a light shielding film with first and second regions on a substrate;

forming a photosensitive insulation film on said light shielding film; and

exposing said photosensitive insulation film to position said light shielding film at boundaries of said first and second
5 regions by using a photomask.

5. The method of manufacturing a liquid crystal display device according to Claim 4, wherein said step of forming said light shielding film further forms thin film transistors by using the same
10 material as said light shielding film.

6. A method of manufacturing a liquid crystal display device comprising the steps of:

15 forming any one of reflective, light shielding or diffusing films on a back surface of a substrate;

forming a photosensitive insulation film on a front surface of said substrate; and

exposing said insulation film by using a photomask.